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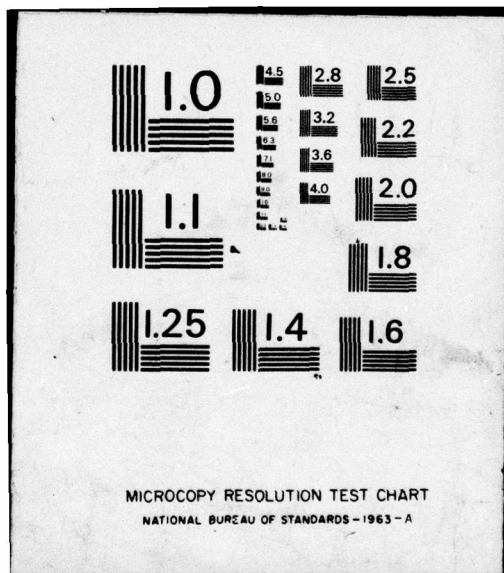
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PROPERTIES OF PHOTODETECTORS

(Photodetector Series, 97th Report)

Spatial Sensitivity of LWIR Detectors

September 1976

Electronic Material Sciences Division
Research and Development, January-June 1976

Prepared for
ARMY MATERIALS AND MECHANICS RESEARCH CENTER

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FOREWORD

This report, prepared as part of the Joint Services Infrared Sensitive Element Testing Program, is the 97th in a series concerned with the various physical properties of photodetectors. This series of reports is intended to keep the users of infrared detectors abreast of state-of-the-art devices.

OBJECTIVE

Develop techniques and apparatus for measuring the performance characteristics of new or improved infrared photodetectors. Define and measure the pertinent detector parameters such as spectral response, noise spectra, frequency response, and noise equivalent power. Report the resultant data in suitable format to the Department of Defense, other governmental agencies, and their contractors.

RESULTS

Spatial sensitivity measurements have been made on a number of intrinsic and extrinsic photoconductive detectors. The measurements were made using a newly developed apparatus capable of generating the appropriate background photon flux level and wavelength.

ADMINISTRATIVE INFORMATION

Work was done from January to June 1976 by the Infrared Devices Branch of the Electronic Material Sciences Division under program element 63304A, project 0, task ARMY (NELC T301), for the Army Materials and Mechanics Research Center. This report is coauthored by DC Arrington, RL Bates, WL Eisenman, and MH Sweet and was approved for publication September 1976.

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- Top right: Two checkboxes, the top one is checked.
- Middle: A line with the text "BY" followed by a signature.
- Bottom: A line with the text "DATE" followed by a date.
- Bottom right: A line with the text "APPROVED" followed by a signature.

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TABLE

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INTRODUCTION

The use of infrared detectors in space sensors has created a need to characterize the uniformity of response over the sensitive area of the detector under low-background photon flux environments. A low-background, spot-scanning apparatus has been built and several types of extrinsic and intrinsic detectors have been measured. The spot-scanning apparatus will be discussed briefly and data describing the sensitivity contours of several low-background detectors will be presented.

SPOT-SCANNER APPARATUS

The spot scanner consists of four basic parts. A cryogenic Dewar provides the necessary environment to cool the detector being measured and to cool radiation shields that constitute a cold optical cavity. The cold optical cavity surrounds the detector and optical system and maintains the low infrared (IR) background photon flux necessary for the measurement. The optical system, consisting of a PbSnTe light-emitting diode (LED), integrating cavity, pin-hole aperture, and Ge lenses, produces a small spot of IR radiation on the surface of the detector. An x-y drive mechanism translates the entire optical system to scan the spot over the plane of the detector.

The performance characteristics of the spot scanner are summarized in table 1.

TABLE 1. SPOT-SCANNER CHARACTERISTICS.

Background photon flux	$<10^8$ (photon/s-cm ²)
Optical wavelength	~ 10 (μm)
Spot size	60 (μm dia)
Scan length	10 (mm, x and y)
Focus adjustment	3 (mm)
Mechanical repeatability	~ 10 (μm , y-axis)
Detector operating temperature	4 to 20 (K)
Cool down time	6½ (h, 300 to 4 K)
Hold time	2 (h)

The scan length for both x- and y-axes is 10 millimetres. The cold optical system produces a spot about 60 micrometres in diameter at a wavelength of approximately 10 micrometres. Mechanical repeatability is on the order of 10 micrometres. The z-axis provides a focus adjustment of 3 millimetres. Measurements made with a calibrated detector show that the background is less than 10^8 photons/s-cm². The diode radiation source can be modulated at any frequency between 2 and 1000 Hz. Cool-down time is about 6½ hours and Dewar hold time is 2 hours. The apparatus can be refilled with helium in about 5 minutes without interrupting measurements.

Figure 1 is an external view of the spot-scanner assembly. At the bottom are the x-y indexing motors, drive screws, and precision linear-motion stages. The lower half of the Dewar contains the scanning mechanism and optical system. The section above the vacuum flange is a standard liquid helium-cooled Dewar.

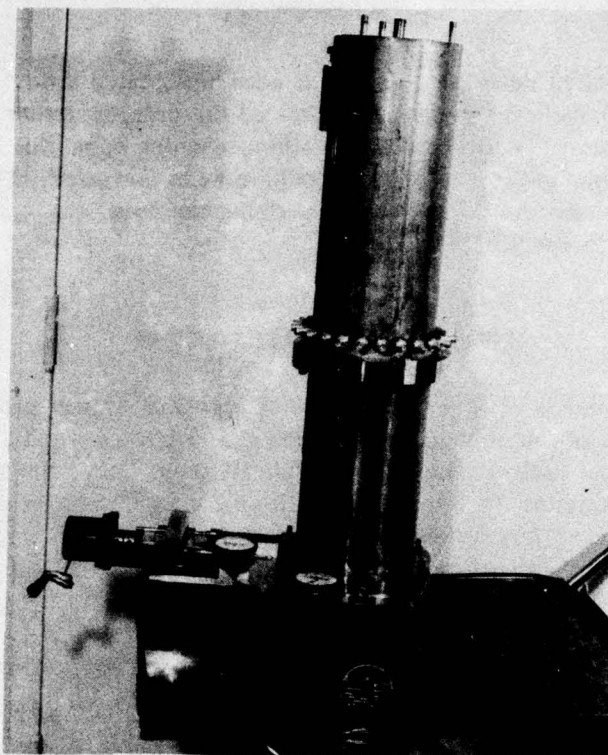


Figure 1. External view of the spot-scanner apparatus.

The data are obtained one line at a time by scanning the spot along the y-axis. The entire sensitive area of the detector is measured by generating line scans at many positions along the x-axis. The apparatus is capable of generating a number of scan patterns but the "scan in y, step in x" pattern is normally used. Each scan along the y-axis is made in the same direction to minimize backlash. For all the data in this report, the velocity of the spot in the y-direction was made small enough to allow the detector signal to reach equilibrium.

The IR radiation is modulated in the form of a symmetrical square wave. The electrical signal from the detector is amplified and then passed through a narrow-band filter tuned to the modulation frequency. A modulation frequency of 10 Hz was used for the data presented here. Most of the measurements were made with a signal-to-noise ratio of 10^2 to 10^3 in a 1-Hz bandwidth. After passing through the narrow-band filter, the detector signal is rectified, filtered, and sent to an automatic data processing (ADP) system. The rectified signal is digitized and stored in the form of signal amplitude as a function of spot position in the x-y plane. The ADP system also controls the x- and y-drive motors on the spot scanner and can automatically scan a detector or array of detectors.

The ADP system can output the accumulated data in two formats. A pseudo three-dimensional format showing signal amplitude distribution over the x-y plane can be generated using an x-y plotter. This format can be generated automatically and provides a simple qualitative description of the detector. A "sensitivity contour" format

can be produced to obtain a more quantitative description of the detector. Unfortunately, due to system hardware limitations, this format must be plotted by hand. Figure 2 shows data plotted in the two formats.

DATA

Measurements of spatial sensitivity have been made on a large number of detectors. These detectors are representative of several types and several manufacturers. For this report, the detectors have been divided into three groups:

- (1) photoconductive HgCdTe
- (2) extrinsic silicon with lateral electrodes (electric field perpendicular to direction of incident radiation)
- (3) extrinsic silicon with transparent electrodes (electric field parallel to incident radiation).

Data are presented for several detectors of each type.

PHOTOCONDUCTIVE HgCdTe

The data shown in figures 3 and 4 are for two detectors (#1 and 2) of a 6-element array. This array (U-1) was manufactured from a single slab of HgCdTe. The nominal dimensions of the geometrical area are $0.012'' \times 0.023''$. In both cases the spatial sensitivity is not uniform and in the case of detector #2, one half of the detector is relatively insensitive.

The data shown in figures 5, 6, and 7 are for three individual detectors out of a total of four which were on a common mount. Detector S-14-32-H2 #2 had geometrical dimensions of $0.020'' \times 0.020''$, and detectors S-12-49 #2 and S-12-49 #3 had dimensions of $0.040'' \times 0.040''$. Again, the spatial sensitivity is nonuniform and, in the cases of the two $0.040'' \times 0.040''$ detectors, a large fraction of the geometrical area is quite insensitive.

Detectors S-14-39 #4 and S-14-39 #5, whose spatial sensitivities are shown in figures 8 and 9, were two individual detectors from a total of five on a common mount. Figures 10 and 11 show data on two other individual detectors from a group of five. Figures 12, 13, and 14 show data on three of six individual detectors. All detectors presented in figures 8 through 14 had geometrical dimensions of $0.020'' \times 0.020''$.

EXTRINSIC SILICON-LATERAL ELECTRODES

Data are shown for two detectors, ELMS 200 and HST 036, both of which are arsenic-doped silicon detectors. Detector dimensions are $0.058'' \times 0.050'' \times 0.080''$ for ELMS 200 and $0.029'' \times 0.076'' \times 0.040''$ for HST 036. The first two dimensions represent the active surface and the third dimension is the thickness of the devices. Both detectors are soldered to a metallic mount which is used as the ground bias electrode. The second electrode is soldered to the opposite side. This mounting procedure renders two surfaces insensitive to infrared radiation but leaves the other four surfaces exposed and sensitive. These exposed surfaces, together with reflecting metallic surfaces below

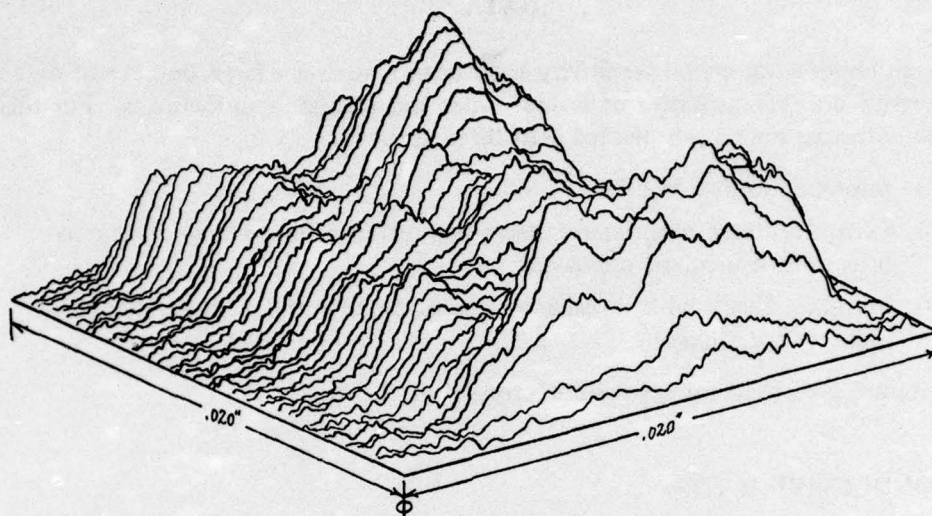


Figure 2-A. Pseudo three-dimensional data format.

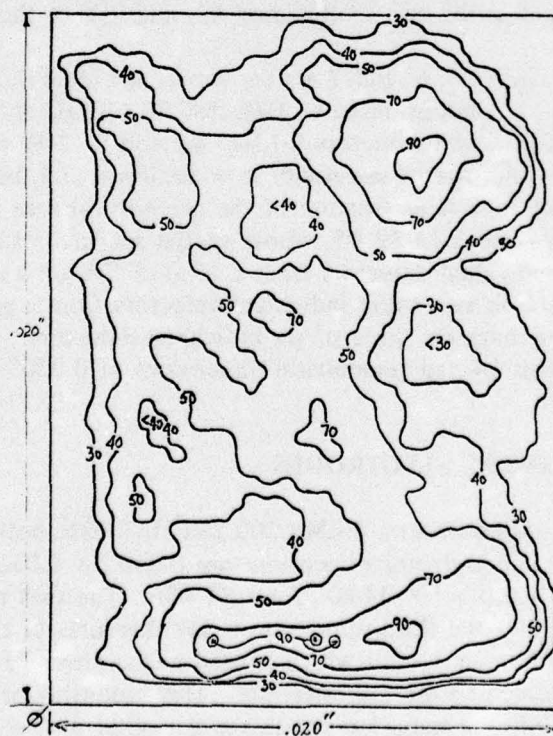


Figure 2-B. Sensitivity contour data format.

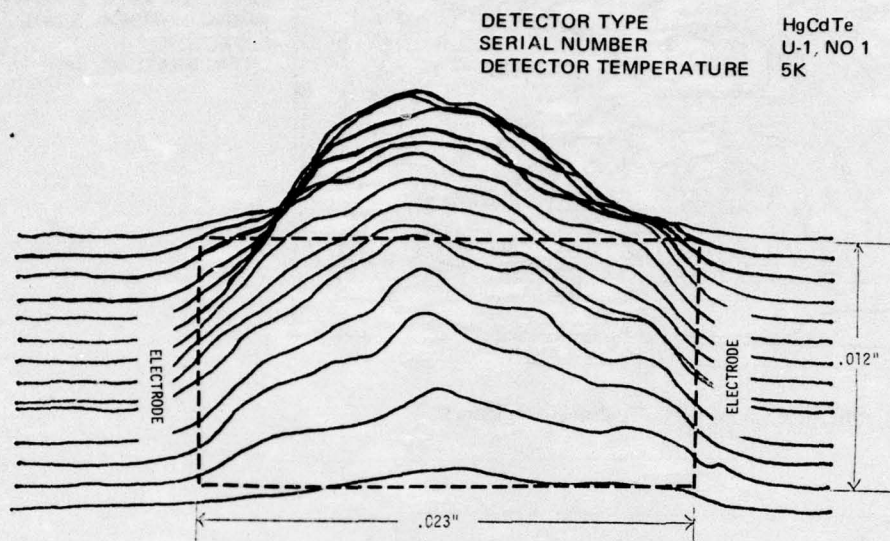


Figure 3. Element 1 of a six-element HgCdTe array.

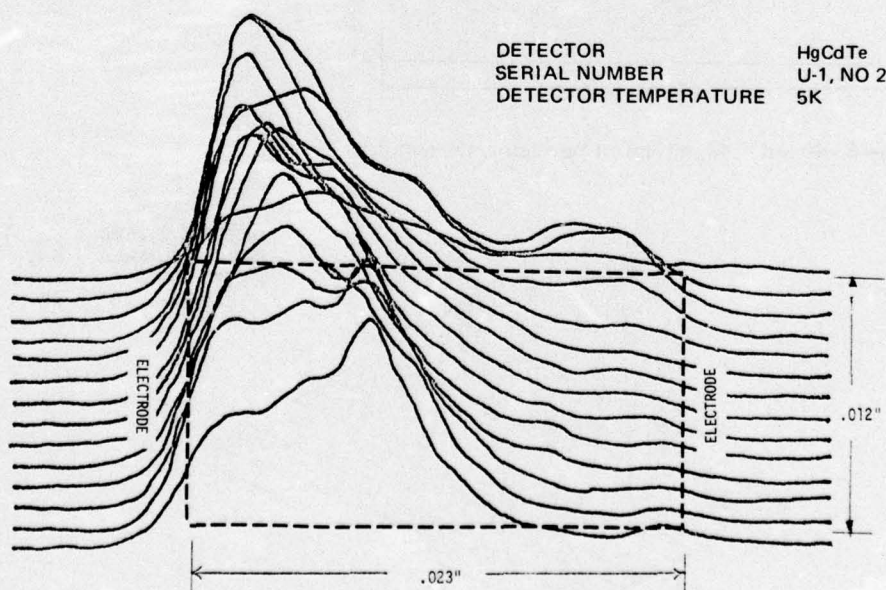
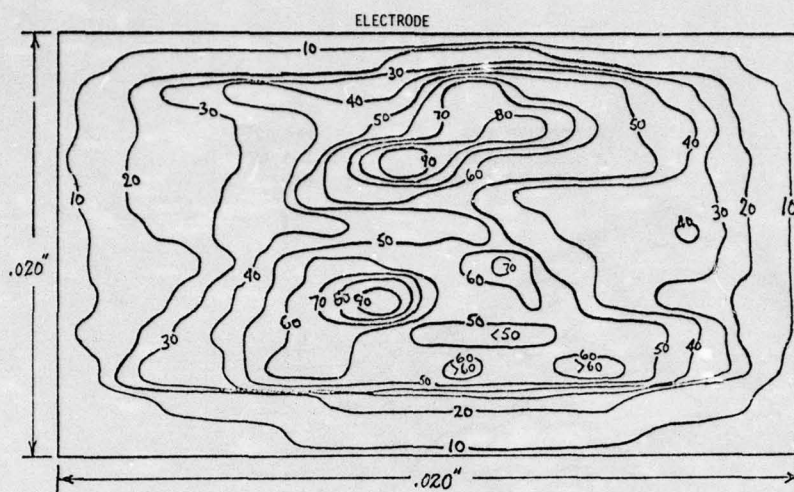
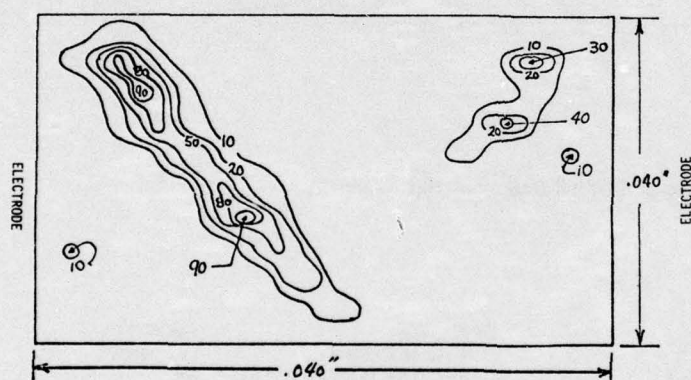


Figure 4. Element 2 of a six-element HgCdTe array.



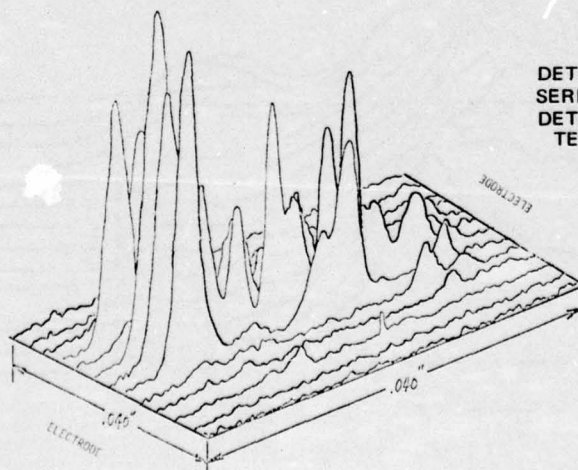
DETECTOR TYPE HgCdTe
SERIAL NUMBER 5-14-32-H2, NO 2
DETECTOR
TEMPERATURE 5K

Figure 5. 20 mil X 20 mil HgCdTe detector, element 2.



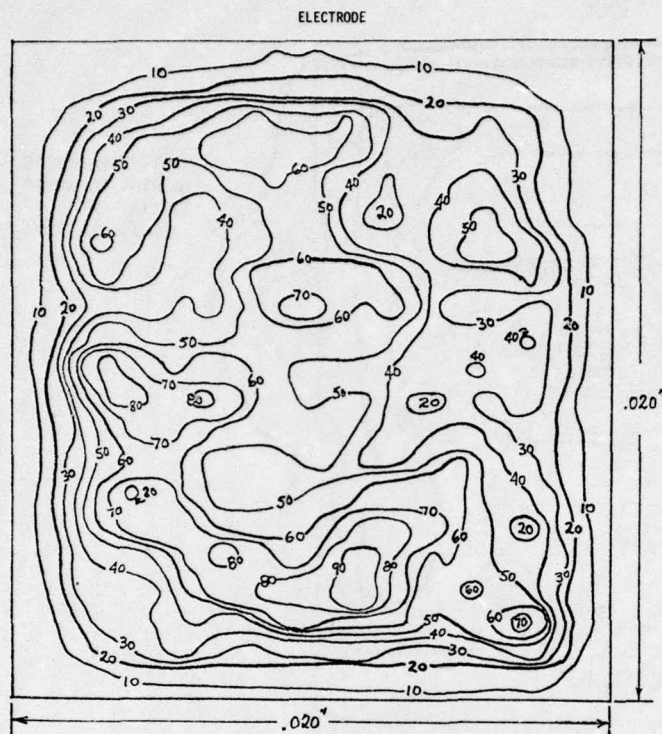
DETECTOR TYPE HgCdTe
SERIAL NUMBER S-12-49, NO 2
DETECTOR
TEMPERATURE 5K

Figure 6. 40 mil X 40 mil HgCdTe detector, element 2.



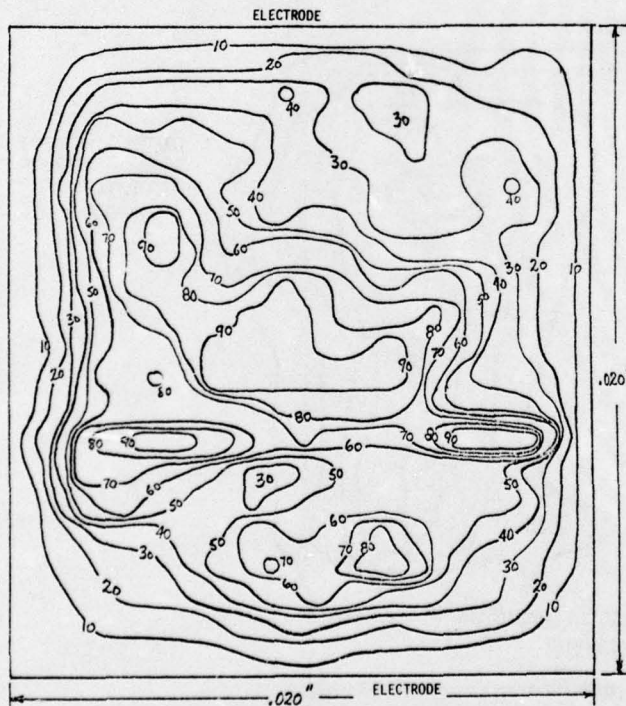
DETECTOR TYPE HgCdTe
SERIAL NUMBER S-12-49, NO 3
DETECTOR
TEMPERATURE 5K

Figure 7. 40 mil X 40 mil HgCdTe detector, element 3.



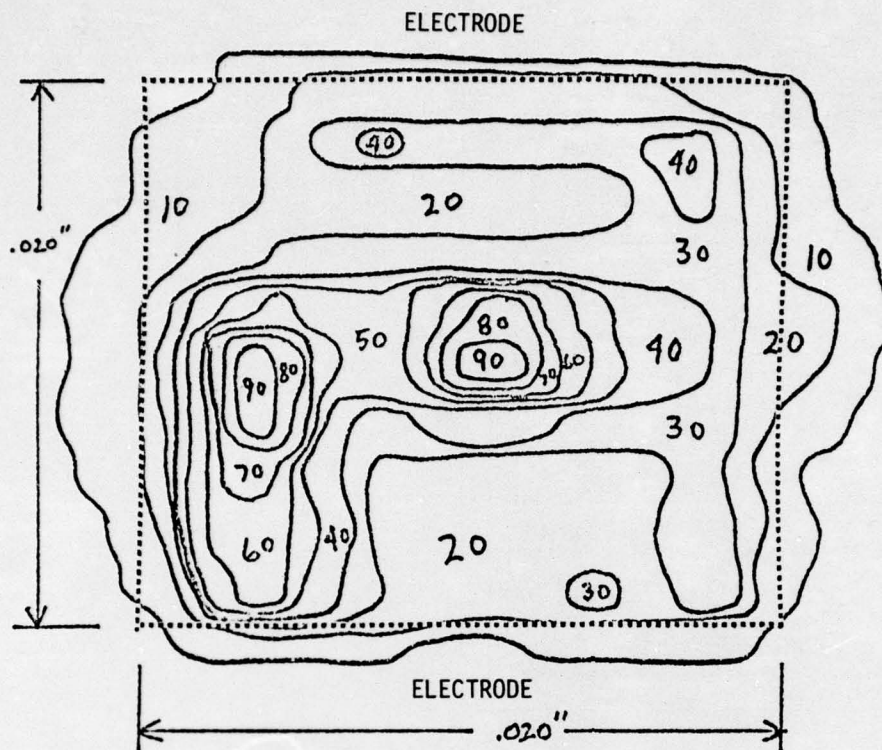
DETECTOR TYPE HgCdTe
 SERIAL NUMBER S-14-39, NO 4
 DETECTOR
 TEMPERATURE 5K

Figure 8. Element 4 of a five-element HgCdTe array.



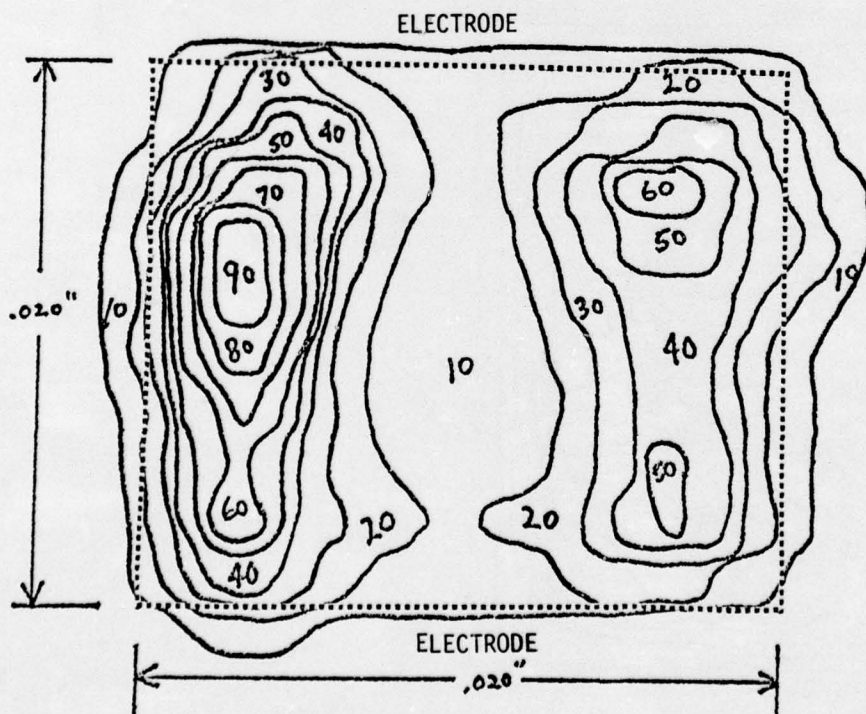
DETECTOR TYPE HgCdTe
 SERIAL NUMBER S-14-39, NO 5
 DETECTOR
 TEMPERATURE 5K

Figure 9. Element 5 of a five-element HgCdTe array.



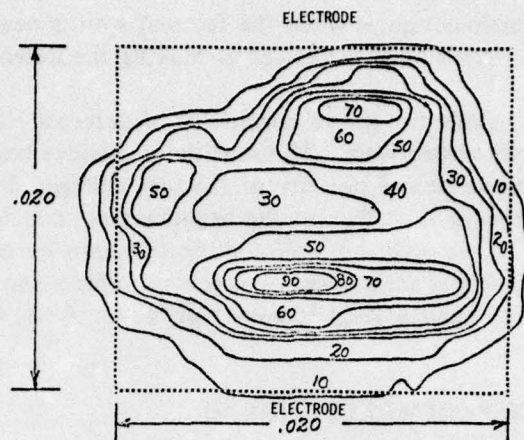
DETECTOR TYPE HgCdTe
 SERIAL NUMBER S-20-38, NO 3
 DETECTOR
 TEMPERATURE 5K

Figure 10. Element 3 of a five-element HgCdTe array.



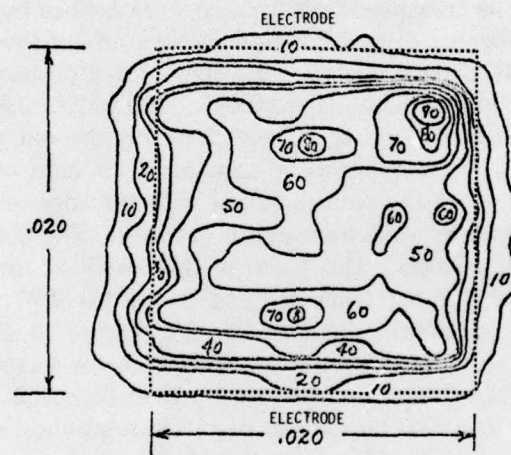
DETECTOR TYPE HgCdTe
 SERIAL NUMBER S-20-38, NO 4
 DETECTOR
 TEMPERATURE 5K

Figure 11. Element 4 of a five-element HgCdTe array.



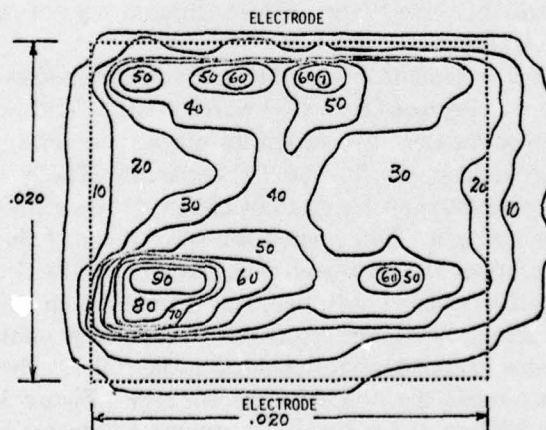
DETECTOR TYPE HgCdTe
 SERIAL NUMBER 2-R2-142, NO 6
 DETECTOR
 TEMPERATURE 5K

Figure 12. 20 mil X 20 mil HgCdTe detector, element 6.



DETECTOR TYPE HgCdTe
 SERIAL NUMBER S-16-35-HI, NO 7
 DETECTOR
 TEMPERATURE 5K

Figure 13. 20 mil X 20 mil HgCdTe detector, element 7.



DETECTOR TYPE HgCdTe
 SERIAL NUMBER S-16-35-HI, NO 8
 DETECTOR
 TEMPERATURE 5K

Figure 14. 20 mil X 20 mil HgCdTe detector, element 8.

the detector, give rise to anomalous signals when the focused spot is near the nominal active area. These additional signals have the effect of making the detector "look" larger than one would expect.

Figures 15, 16, and 17 show the spatial sensitivity of detector ELMS 200 at bias voltages of +5, -5, and -10 volts respectively. The sensitivity, besides being nonuniform, is seen to be dependent on the value and polarity of the bias voltage. In particular, the area of greatest sensitivity seems to shift toward the negative electrode to a degree dependent on the bias. The effect of the reflected light can also be seen by comparing the "sensitive" area with the geometrical area. The same general effects can be seen for detector HST 036, which is shown in figures 18, 19, and 20 at biases of +8, +3, and -3 volts.

EXTRINSIC SILICON-TRANSPARENT ELECTRODES

Data are shown for six detectors fabricated with transparent electrodes. All detectors of this type were made from a piece of silicon larger than the desired detector size. The active areas (under the transparent electrodes) were defined by means of an evaporated metallic pattern. Figures 21 and 22 show the spatial sensitivity of two elements of a 10-element array (HFP 042) made from a single piece of arsenic-doped silicon (monolithic). The detector dimensions are $0.012'' \times 0.032''$. The data show extremely good uniformity across the surface. These detectors showed good uniformity over a wide range of bias values. The nonuniform scans near the ends of the detectors were due to a slight misalignment of the scan direction with the edge of the detector.

Figure 23 shows the data for a silicon-bismuth detector. The detector is in the shape of a truncated equilateral triangle. The width of the base is about $0.019''$ and the altitude is $0.270''$. The width at the truncated end is about $0.003''$. The measured element is one of an 8-element monolithic array (LTV-12). Figure 24 shows data on an arsenic-doped silicon detector of similar dimensions. This detector was also one element of an 8-element array (VSD B224-01). Good uniformity is to be noted for both of these detectors. Because of mechanical limitations of the spot scanner, scans over the entire sensitive areas of these two detectors were not possible.

Data on one element of a 5-element monolithic array of Si:As detectors are shown in figures 25, 26, and 27. The area of this detector was $0.020'' \times 0.020''$. Data are shown at three different flux levels (varying over three orders of magnitude) and good uniformity is seen in all cases.

Data for one element of a 5-element monolithic Si:Bi array are shown in figures 28, 29, and 30. The data shown in figures 28 and 29 were obtained with a bias of -10 volts and two flux levels approximately two orders of magnitude apart. The distinct nonuniformity as well as the dependence on flux level is apparent. These data can be qualitatively explained by assuming that the transparent electrode has a resistance which approaches that of the detector material. Thus, when the spot of signal flux strikes the detector it lowers the resistance under the spot and thus reduces the local electric field. Conversations with the manufacturers have confirmed that difficulties in certain manufacturing processes can lead to a high resistance electrode. Visual inspection of the opaque film surrounding the sensitive area revealed what appeared to be holes. These holes undoubtedly produced the signals outside the nominal detector area. Figure 30 shows the detector under the same flux condition as for figure 29 but for a detector bias of -5 volts.

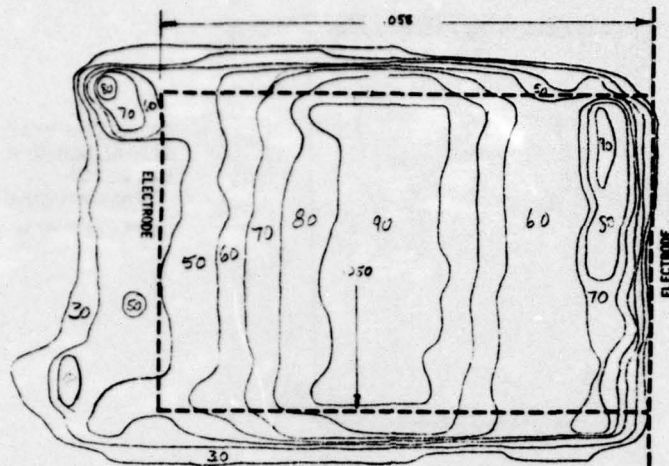


Figure 15. 58 mil X 50 mil Si:As detector, +5 volts bias.

DETECTOR TYPE Si:As
 SERIAL NUMBER ELMS-200
 DETECTOR TEMPERATURE 5K
 DETECTOR BIAS +5 V

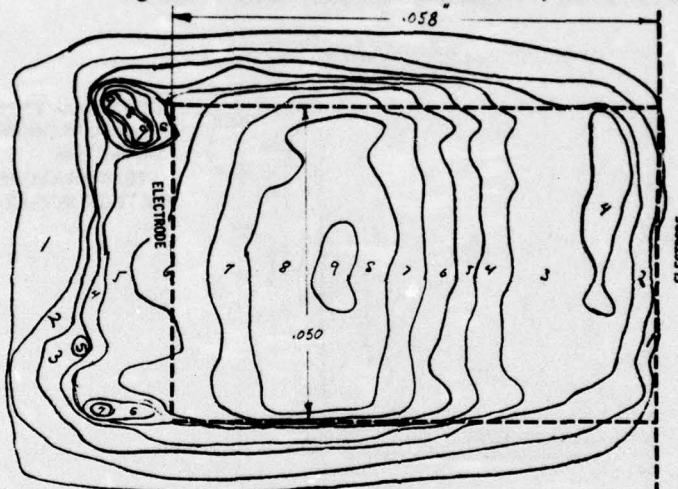


Figure 16. 58 mil X 50 mil Si:As detector, -5 volts bias.

DETECTOR TYPE Si:As
 SERIAL NUMBER ELMS-200
 DETECTOR TEMPERATURE 5K
 DETECTOR BIAS -5V

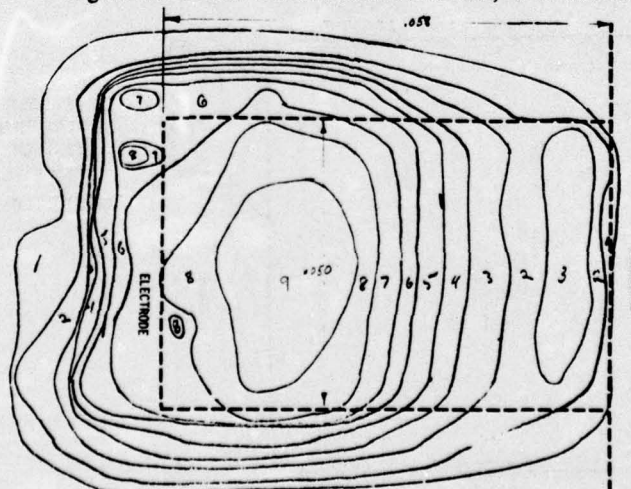
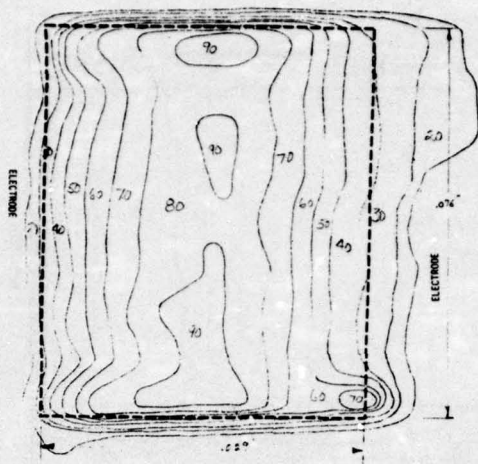


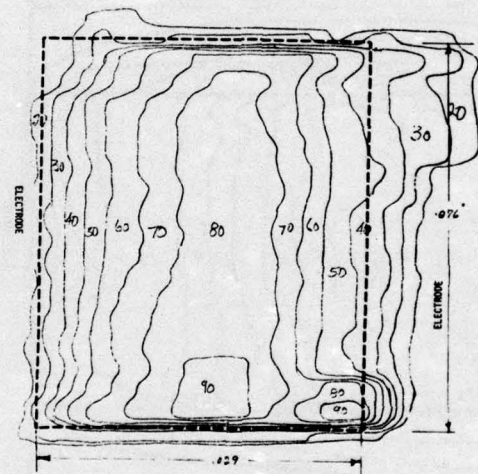
Figure 17. 58 mil X 50 mil Si:As detector, -10 volts bias.

DETECTOR TYPE Si:As
 SERIAL NUMBER ELMS-200
 DETECTOR TEMPERATURE 5K
 DETECTOR BIAS -10V



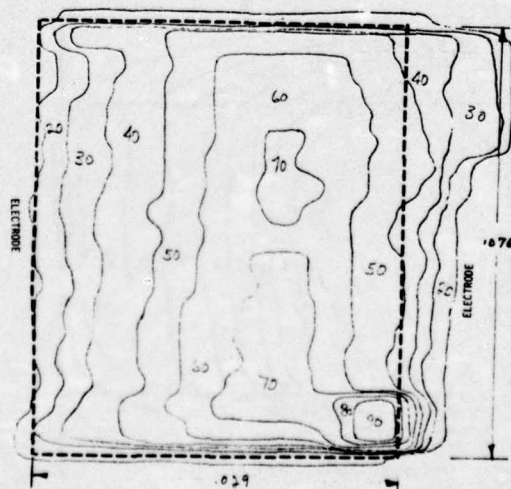
DETECTOR TYPE Si:As
 SERIAL NUMBER HST-036
 DETECTOR
 TEMPERATURE 5K
 DETECTOR BIAS +8V

Figure 18. 29 mil X 76 mil Si:As detector, +8 volts bias.



DETECTOR TYPE SiAs
 SERIAL NUMBER HST-036
 DETECTOR
 TEMPERATURE 5K
 DETECTOR BIAS +3V

Figure 19. 29 mil X 76 mil Si:As detector, +3 volts bias.



DETECTOR TYPE Si:As
 SERIAL NUMBER HST-036
 DETECTOR
 TEMPERATURE 5K
 DETECTOR BIAS -3V

Figure 20. 29 mil X 76 mil Si:As detector, -3 volts bias.

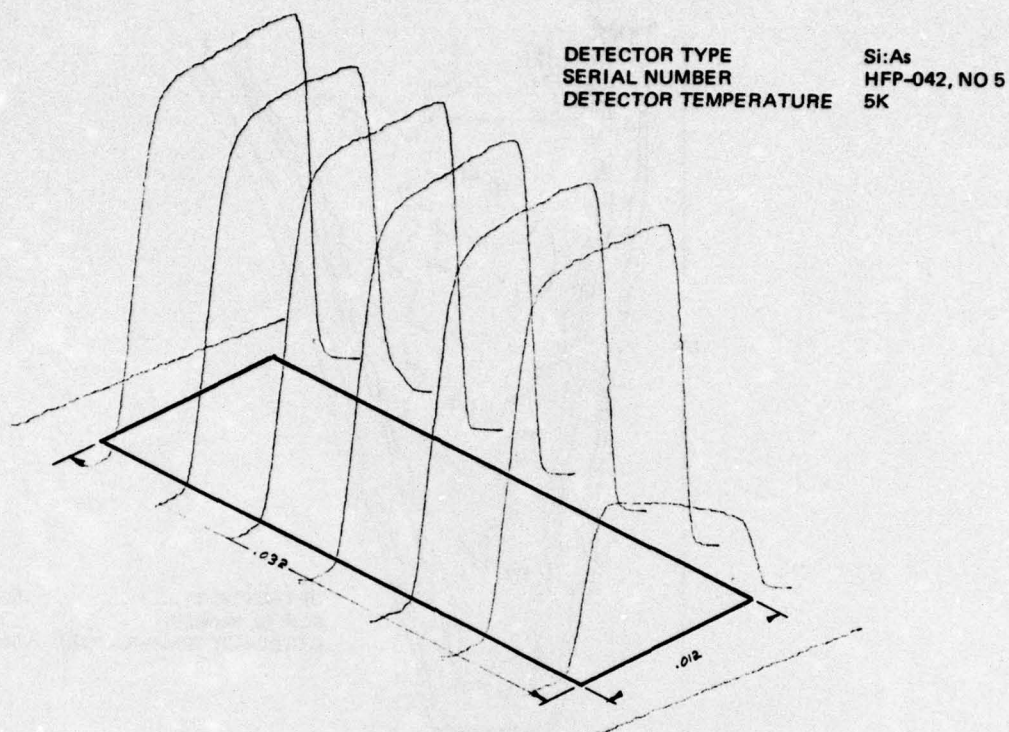


Figure 21. Element 5 of a 10-element Si:As monolithic array.

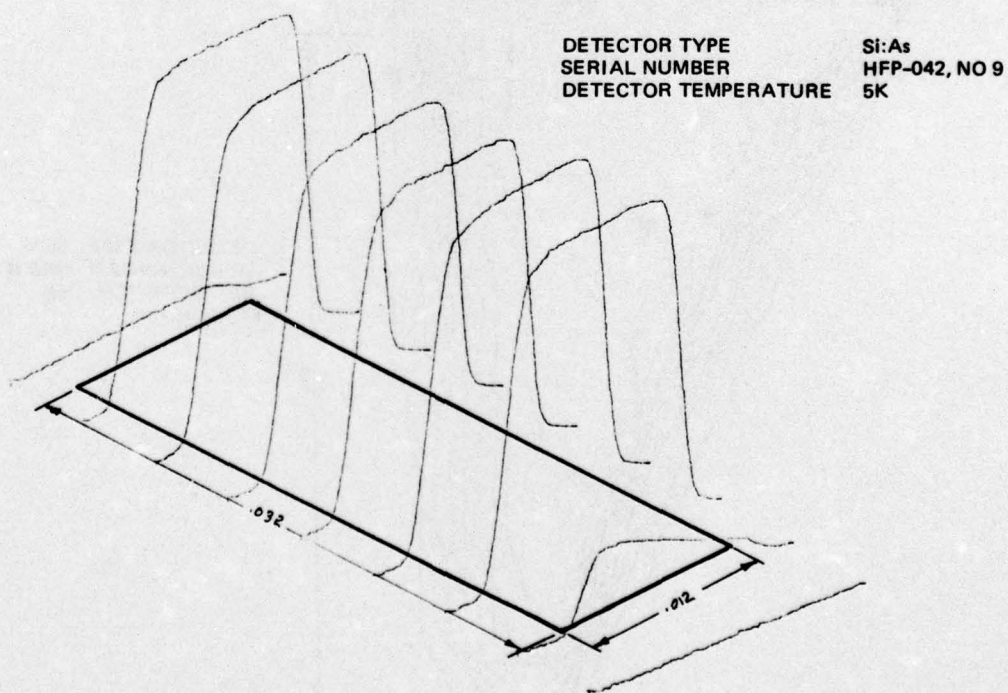


Figure 22. Element 9 of a 10-element Si:As monolithic array.

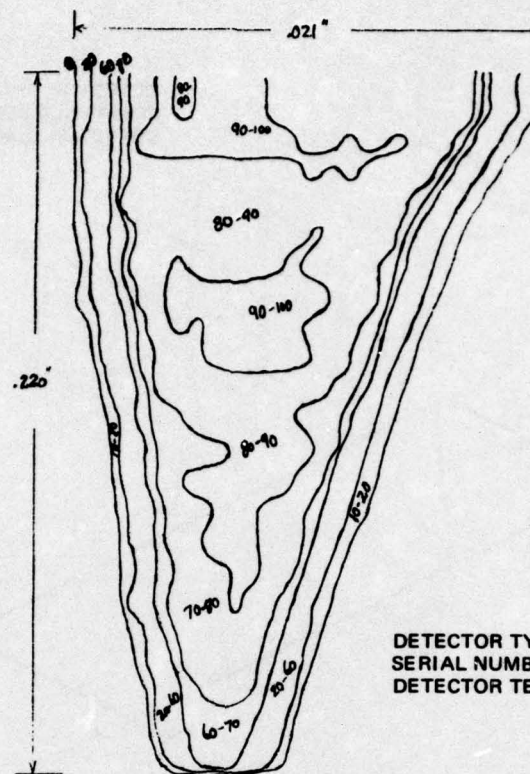


Figure 23. Si:Bi detector fabricated with transparent electrodes.

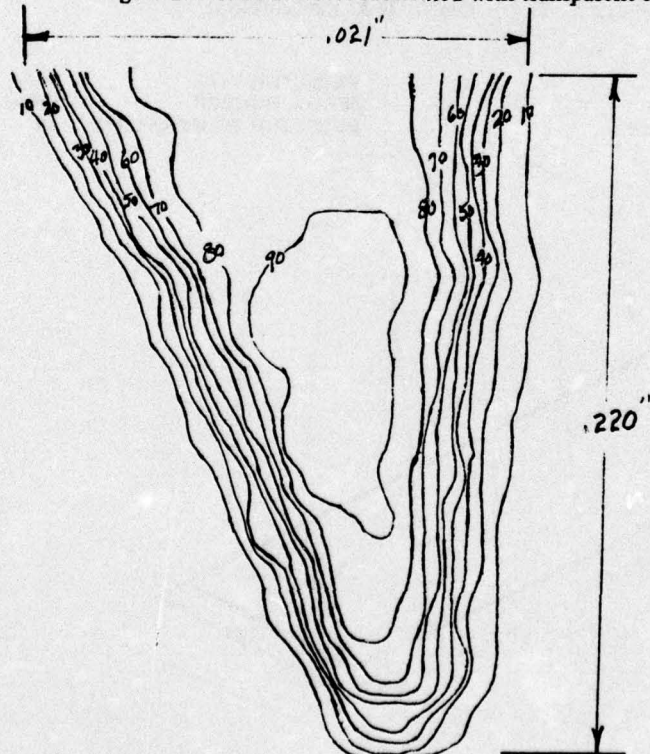
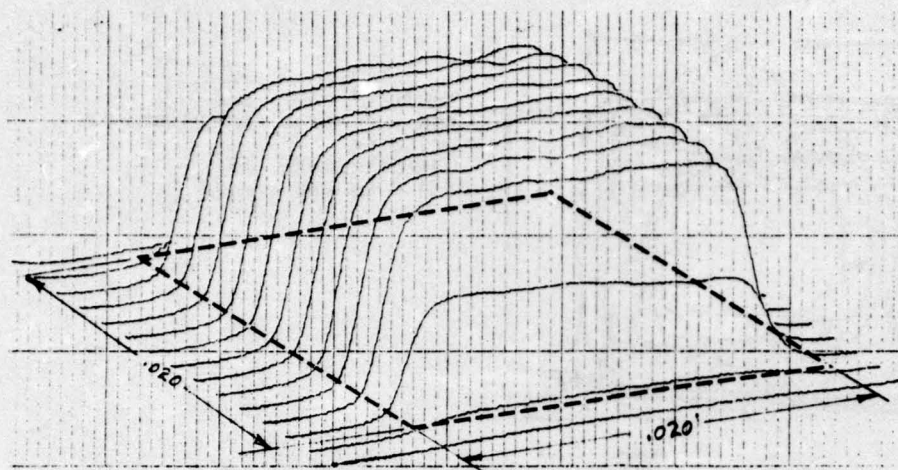
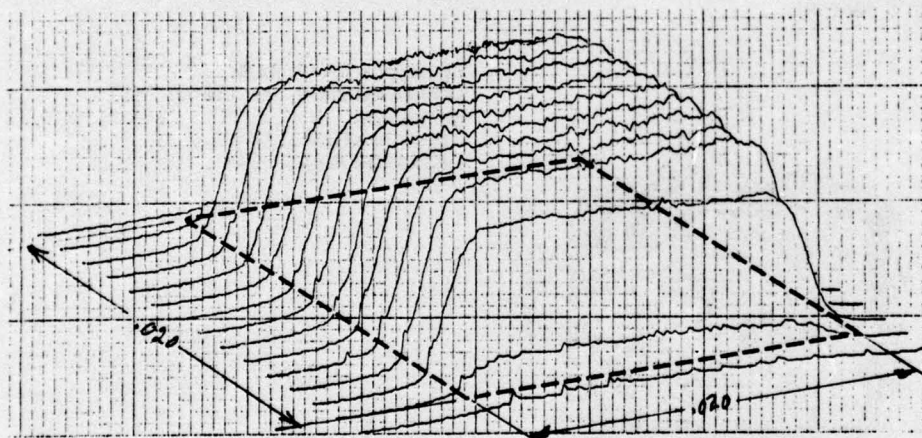


Figure 24. Si:As detector fabricated with transparent electrodes.



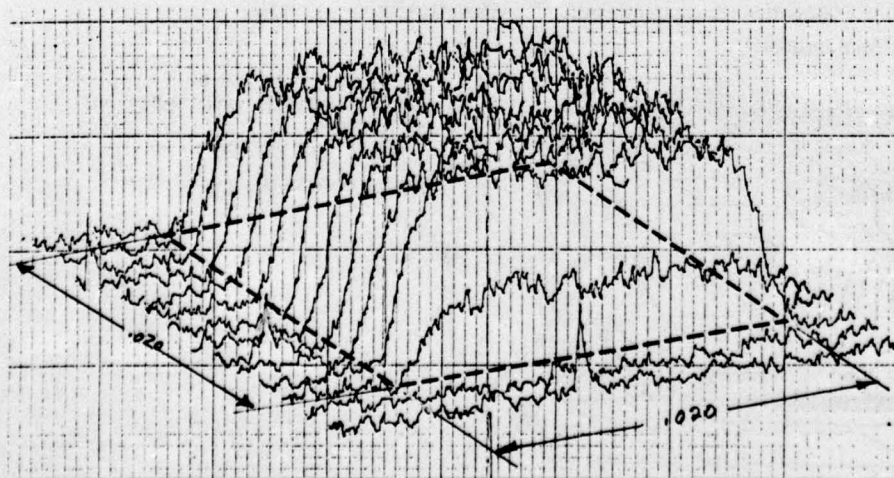
DETECTOR TYPE Si:As
 SERIAL NUMBER AN-188-001, NO 4
 DETECTOR
 TEMPERATURE 5K
 DETECTOR BIAS -2.5V

Figure 25. Si:As detector with transparent electrodes, maximum signal of 8 millivolts.



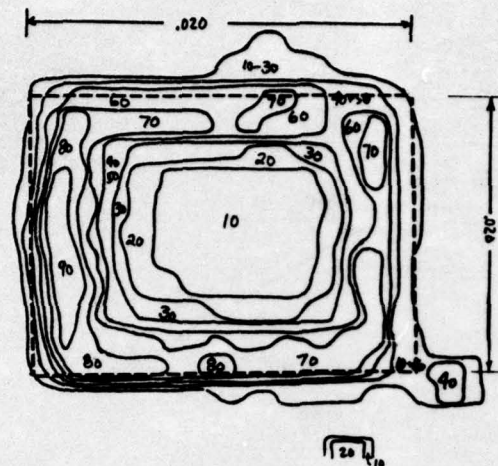
DETECTOR TYPE Si:As
 SERIAL NUMBER AN-188-001, NO 4
 DETECTOR
 TEMPERATURE 5K
 DETECTOR BIAS -2.5V

Figure 26. Si:As detector with transparent electrodes, maximum signal of 800 microvolts.



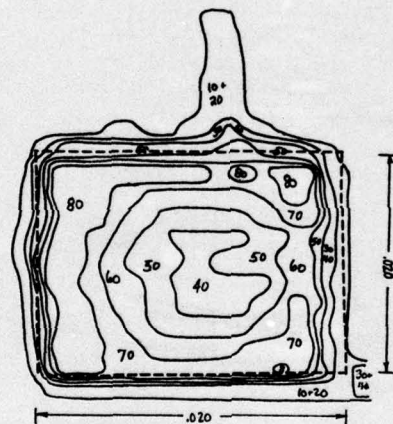
DETECTOR TYPE Si:As
 SERIAL NUMBER AN-188-001, NO 4
 DETECTOR
 TEMPERATURE 5K
 DETECTOR BIAS -2.5V

Figure 27. Si:As detector with transparent electrodes, maximum signal of 8 microvolts.



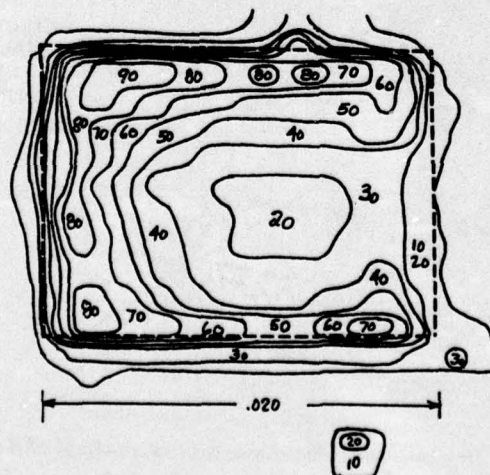
DETECTOR TYPE Si:Bi
 SERIAL NUMBER AN-184-001, NO 2
 DETECTOR TEMPERATURE 5K
 DETECTOR BIAS -10V

Figure 28. Si:Bi detector with defective transparent electrode, -10 volts bias and a maximum signal of 8 millivolts.



DETECTOR TYPE Si:Bi
 SERIAL NUMBER AN-184-001, NO 2
 DETECTOR TEMPERATURE 5K
 DETECTOR BIAS -10V

Figure 29. Si:Bi detector with defective transparent electrode, -10 volts bias and a maximum signal of 80 microvolts.



DETECTOR TYPE Si:Bi
 SERIAL NUMBER AN-184-001, NO 2
 DETECTOR TEMPERATURE 5K
 DETECTOR BIAS -5V

Figure 30. Si:Bi detector with defective transparent electrode, -5 volts bias and a maximum signal of 80 microvolts.

CONCLUSIONS

The spatial sensitivities of 32 low-background photoconductive HgCdTe detector elements have been measured to date. In all cases the data have shown substantial variations in signal amplitude over the sensitive area of the detector. Signal variations of 50% over a distance of a few mils are not uncommon. In several instances the spatial structure appeared to be limited by the 2-mil-diameter spot used to obtain the data. In the worst cases, less than half of the geometrical area of the detectors exhibited any appreciable photoresponse.

Several extrinsic low-background detectors have been measured. The spatial characteristics of extrinsic detectors are dependent upon the geometry of the bias field. The spatial characteristics of detectors having the bias field perpendicular to the incident radiation are dependent upon the magnitude and polarity of the applied bias. Other data¹ indicate that the spatial sensitivity of detectors of this type will be dependent upon the spectral and temporal characteristics of the signal radiation as well as upon several other operating parameters.

Few extrinsic detectors utilizing transparent electrodes have been measured. The limited data indicate that this type of detector can have good performance characteristics and uniform spatial sensitivity. However, the transparent electrode must have a relatively low resistivity in order to produce satisfactory performance.

¹ "Characteristics of Detectors Having Partially Illuminated Sensitive Areas," C Sayre, *et al*, Minutes of the Meeting of the IRIS Specialty Group on IR Detectors, 1976, Environmental Research Institute of Michigan

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